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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/761,247	01/22/2004	Hasan Nejad	M4065.0513/P513-A	2010	
24998 7	590 03/06/2006		EXAM	INER	
DICKSTEIN SHAPIRO MORIN & OSHINSKY LLP			PRENTY,	PRENTY, MARK V	
-	2101 L Street, NW Washington, DC 20037		ART UNIT	PAPER NUMBER	
			2822		

DATE MAILED: 03/06/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

•	Application No.	Applicant(s)		
Advisory Action	10/761,247	NEJAD ET AL.		
Before the Filing of an Appeal Brief	Examiner	Art Unit		
	MARK PRENTY	2822		
The MAILING DATE of this communication app	pears on the cover sheet with the	correspondence address		
THE REPLY FILED 21 February 2006 FAILS TO PLACE THI	S APPLICATION IN CONDITION F	OR ALLOWANCE.		
 The reply was filed after a final rejection, but prior to or this application, applicant must timely file one of the fol places the application in condition for allowance; (2) a l (3) a Request for Continued Examination (RCE) in comfollowing time periods: 	llowing replies: (1) an amendment, a Notice of Appeal (with appeal fee) in apliance with 37 CFR 1.114. The rep	affidavit, or other evidence, which or compliance with 37 CFR 41.31; or		
 a) The period for reply expires 3 months from the mailing date b) The period for reply expires on: (1) the mailing date of this Ac 		he final rejection, whichever is later. In no		
 The period for reply expires on: (1) the mailing date of this Adevent, however, will the statutory period for reply expire later 				
Examiner Note: If box 1 is checked, check either box (a) or (I MONTHS OF THE FINAL REJECTION. See MPEP 706.07		FIRST REPLY WAS FILED WITHIN TWO		
Extensions of time may be obtained under 37 CFR 1.136(a). The date of been filed is the date for purposes of determining the period of extension CFR 1.17(a) is calculated from: (1) the expiration date of the shortened sabove, if checked. Any reply received by the Office later than three monte earned patent term adjustment. See 37 CFR 1.704(b). NOTICE OF APPEAL	and the corresponding amount of the fee statutory period for reply originally set in the	. The appropriate extension fee under 37 e final Office action; or (2) as set forth in (b		
 The Notice of Appeal was filed on A brief in cor of filing the Notice of Appeal (37 CFR 41.37(a)), or any Since a Notice of Appeal has been filed, any reply must AMENDMENTS 	extension thereof (37 CFR 41.37(e))), to avoid dismissal of the appeal.		
 The proposed amendment(s) filed after a final rejection (a) They raise new issues that would require further of (b) They raise the issue of new matter (see NOTE be (c) They are not deemed to place the application in both careful and for a proposition of the control of the contr	consideration and/or search (see NC low);	OTE below);		
appeal; and/or (d) They present additional claims without canceling NOTE: (See 37 CFR 1.116 and 41.33(a)		ejected claims.		
4. The amendments are not in compliance with 37 CFR 1	• •	Compliant Amendment (PTOL-324)		
5. Applicant's reply has overcome the following rejection(instrument (1 1 0 2 0 2 1).		
6. Newly proposed or amended claim(s) would be the non-allowable claim(s).		e, timely filed amendment canceling		
7. For purposes of appeal, the proposed amendment(s): a how the new or amended claims would be rejected is proposed amendment(s) is (or will be) as follows: Claim(s) allowed: Claim(s) objected to: 53. Claim(s) rejected: 41-52 and 54-60. Claim(s) withdrawn from consideration:		vill be entered and an explanation of		
AFFIDAVIT OR OTHER EVIDENCE				
8. The affidavit or other evidence filed after a final action, because applicant failed to provide a showing of good a and was not earlier presented. See 37 CFR 1.116(e).				
 ☐ The affidavit or other evidence filed after the date of filing a Notice of Appeal, but prior to the date of filing a brief, will not be entered because the affidavit or other evidence failed to overcome all rejections under appeal and/or appellant fails to provide showing a good and sufficient reasons why it is necessary and was not earlier presented. See 37 CFR 41.33(d)(1). ☐ The affidavit or other evidence is entered. An explanation of the status of the claims after entry is below or attached. 				
REQUEST FOR RECONSIDERATION/OTHER	ion of the status of the cialins after	only is below or attached.		

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See Continuation Sheet.

13. Other: __

11. The request for reconsideration has been considered but does NOT place the application in condition for allowance because:

12. Note the attached Information Disclosure Statement(s). (PTO/SB/08 or PTO-1449) Paper No(s).

Mark Prenty

Primary Examiner

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CONTINUATION SHEET OF ADVISORY ACTION (Item 11)

The request for reconsideration has been considered but does NOT place the application in condition for allowance because of the reasons of record (see the Office Action mailed November 21, 2005) and because the applicants' arguments are incorrect as explained below.

As a preliminary matter, the examiner respectfully notes that the applicants have not squarely addressed the thrust of said Office Action (i.e., "Given that Ning discloses that 'various' techniques 'such as' PVD and CVD may be used to form its bottom metal stack, and also discloses electroplating deposition as an alternative to PVD and CVD, Ning discloses that its bottom metal stack, and hence its bottom sense layer, can be electroplated").

The applicants' allegation: "The Office Action continues to assert that the bottom metal stack of Ning could be formed by electroplating," continues to be incorrect. Again, the Office Action does <u>not</u> merely assert that Ning's bottom metal stack "could be formed by electroplating." Again, the maintained rejection actually asserts: "Ning <u>discloses...</u> an electroplated bottom sense layer (i.e., magnetic stack 222's bottom metal stack, which can be formed by electroplating — <u>see column 6, lines 59-62 together with column 6, lines 35-38</u>)." In other words, the maintained rejection asserts and demonstrates that <u>Ning discloses</u> that its bottom sense layer can be formed by electroplating (for example).

The applicants correctly remark: "the bottom metal stack of Ning is referred to as being deposited by techniques <u>such as physical vapor deposition</u> (PVD), evaporation,

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ion sputtering, and chemical vapor deposition," (emphasis added), but the applicant's arguments completely ignore both the cited "such as" language and the examiner's "Given that Ning discloses that 'various' techniques 'such as' PVD and CVD may be used to form its bottom metal stack, and also discloses electroplating deposition as an alternative to PVD and CVD, Ning discloses that its bottom metal stack, and hence its bottom sense layer, can be electroplated," explanation.

The applicants' argument: "As mentioned in Applicants' previous Response, the description in Ning being relied upon in regard to electroplating relates to forming a metal cap layer 220, and not to the formation of an electroplated bottom layer as claimed," is incorrect and ignores the explanation of the rejection, which relies upon Ning's column 6, lines 59-62, together with column 6, lines 35-38. Specifically, the significance of Ning's column 6, lines 35-38, disclosure that "First metal cap layer 220 may be deposited by PVD, CVD, or may be electroless-plated and selectively deposited," is not that metal cap layer 220 may be formed by electroplating but that electroplating is an alternative to PVD and CVD. Accordingly, when Ning later discloses at column 6, lines 59-62, that "Various techniques such as" PVD and CVD may be used to form its bottom metal stack, Ning on the whole has disclosed that the bottom metal stack can also be formed by electroplating.

The applicants' remark: "Applicants respectfully submit that the metal cap layer of Ning is not equivalent to, or the same as the electroplated bottom layer of the claimed invention," is not really on point. Again, the significance of Ning's metal cap layer disclosure is that it discloses electroplating as an alternative to PVD and CVD.

The applicants' allegation: "Ning refers to forming the magnetic stack <u>only</u> by PVD, evaporation, ion sputtering, and CVD," (emphasis added), is incorrect, as evidenced by Ning's column 6, lines 59-62, disclosure: "Various techniques <u>such as physical vapor deposition (PVD)</u>, evaporation, ion sputtering, and chemical vapor deposition (CVD) may be used to deposit the magnetic layers of bottom metal stack" (emphasis added).

The applicants' allegation: "No mention is made to forming the magnetic stack using an electroplating method," is without merit and simply ignores the explanation of the rejection. The issue is not whether Ning makes "mention" of forming the magnetic stack using an electroplating method <u>but whether Ning on the whole discloses forming the magnetic stack using an electroplating method</u>. Ning clearly does disclose forming the magnetic stack using an electroplating method <u>at column 6</u>, lines 59-62, together with column 6, lines 35-38, as explained above.

The applicants' allegation: Ning was clearly aware of the electroplating process based on its reference to the method in relation to the metal cap layer. The Office Action cannot simply stretch the teachings of the cited reference to assert that it refers forming an electroplated bottom layer," is without merit. The Office Action has not "stretched" Ning's teachings; the applicants have simply ignored them taken together. Indeed, the examiner respectfully submits that the applicants' arguments in this regard are somewhat analogous to incorrectly arguing a 35 USC 103 rejection by attacking the combined references individually rather than as a whole.

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Registered practitioners can telephone the examiner at (571) 272-1843. Any voicemail message left for the examiner must include the name and registration number of the registered practitioner calling, and the Application/Control (Serial) Number. Technology Center 2800's general telephone number is (571) 272-2800.

Mark V. Prenty Primary Examiner